







an Open Access Journal by MDPI

Transparent Conductive Films and Their Applications

Guest Editors:

Prof. Dr. Mateusz Smietana

Institute of Microelectronics and Optoelectronics, Warsaw University of Technology, Koszykowa 75, 00-662 Warsaw, Poland

Assoc. Prof. Robert Bogdanowicz

Department of Metrology and Optoelectronics, Faculty of Electronics, Telecommunications and Informatics Gdansk University of Technology, Gdansk, Poland

Deadline for manuscript submissions:

closed (30 November 2019)

Message from the Guest Editors

Interest of scientific community in materials offering both electrical conductivity and optical transparency has intensified in recent years. These materials often need to be very thin. The decrease in thickness stimulates development of novel deposition and processing techniques, but also may result in obtaining materials with novel and fascinating properties. Besides decrease in thickness, the films are often processed to have a certain pattern, as in case of metamaterials. By such processing even metal film can be treated as transparent, but still maintain the electrical conductivity.

Application of these materials is not limited to displays. They are often needed for energy conversion devices or various sensors, especially those offering dual optical and electrical interrogation. Applications and used substrates determines deposition techniques, that need to be tuned to offer thin films with satisfying properties.

It is our pleasure to invite you to submit a manuscript for this Special Issue focused on transparent conductive films. Full papers, communications, and reviews on fabrication, properties, and applications of these films are all welcome.













an Open Access Journal by MDPI

Editor-in-Chief

Prof. Dr. Maryam Tabrizian

1. Department of Biomedical Engineering, Faculty of Medicine and Health Sciences, McGill University, Montreal, QC H3A 2B6, Canada

2. Faculty of Dentistry and Oral Health Sciences, McGill University, 3640 Rue University, Montreal, QC H3A 0C7, Canada

Message from the Editor-in-Chief

Materials (ISSN 1996-1944) was launched in 2008. The iournal covers twenty-five comprehensive biomaterials, energy materials, advanced composites. advanced materials characterization, porous materials, manufacturing processes and svstems. nanomaterials and nanotechnology, smart materials, thin films and interfaces, catalytic materials, carbon materials, materials chemistry, materials physics, optics and photonics, corrosion, construction and building materials. materials simulation and design, electronic materials, advanced and functional ceramics and glasses, metals and alloys, soft matter, polymeric materials, quantum materials, mechanics of materials, green materials, general. Materials provides a unique opportunity to contribute high quality articles and to take advantage of its large readership.

Author Benefits

Open Access: free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility: indexed within Scopus, SCIE (Web of Science), PubMed, PMC, Ei Compendex, CaPlus / SciFinder, Inspec, Astrophysics Data System, and other databases

Journal Rank: JCR - Q2 (Metallurgy and Metallurgical Engineering) / CiteScore - Q1 (Condensed Matter Physics)

Contact Us